

Title (en)
SUBSTRATE PROVIDED WITH A CONFIDENTIAL PATTERN

Title (de)
SUBSTRAT MIT EINEM VERTRAULICHEN MUSTER

Title (fr)
SUBSTRAT ADAPTÉ À ÊTRE MUNI D'UN DESSIN CONFIDENTIEL

Publication
EP 1626651 B1 20060913 (FR)

Application
EP 04731074 A 20040504

Priority
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• CH 9592003 A 20030528

Abstract (en)
[origin: WO2004106085A1] A substrate (10) to be provided with a confidential pattern (40) using normal ink in a concealing region (20), wherein the concealing means (21) of the concealing region (20) is pre-printed with a special ink. Unlike the normal ink, the special ink can be permanently erased using a colour-removing agent (36). The colour-removing agent (36) is deposited on a colour-removing substrate (34) which is bonded to the substrate (10) and can be contacted with the concealing region (20).

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CPC (source: EP)
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